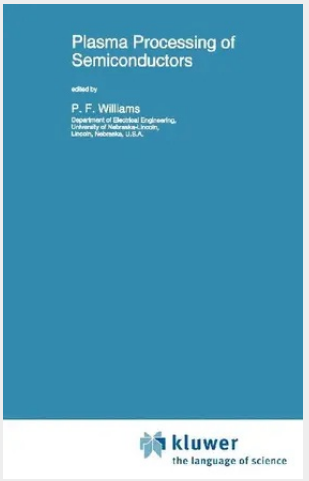
Williams

Plasma Processing of Semiconductors

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320,99 €
299,99 € (zzgl. MwSt.)

Lieferfrist: bis zu 10 Tage

Artikelnummer: 9780792345671
Medium: Buch
ISBN: 978-0-7923-4567-1
Verlag: Springer
Erscheinungstermin: 31.05.1997
Sprache(n): Englisch
Auflage: 1997
Serie: NATO Science Series E:
Produktform: Gebunden
Gewicht: 1098 g
Seiten: 613
Format (B x H): 160 x 241 mm

Kundenservice Verlag Dr. Otto Schmidt KG
Neumannstraße 10, 40235 Düsseldorf | kundenservice@otto-schmidt.de | 0221-93738-997 (Inland)